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	Application No.	Applicant(s)	
Notice of Allowability	10/033,100	YAMAZAKI ET AL.	
	Examin r	Art Unit	
	Renee R Berry	2818	
Th MAILING DATE of this communication appeal claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RID of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this ap or other appropriate communication GHTS. This application is subject to	plication. If not include will be mailed in due	ed course. <b>THIS</b>
1. This communication is responsive to 10/23/03.			
2. The allowed claim(s) is/are <u>9,10 and 22-33</u> .			
<ol> <li>The drawings filed on <u>25 October 2001</u> are accepted by the</li> </ol>	e Examiner.		
<ol> <li>Acknowledgment is made of a claim for foreign priority ur</li> <li>a) ☐ All b) ☐ Some* c) ☐ None of the:</li> </ol>	nder 35 U.S.C. § 119(a)-(d) or (f).		
<ol> <li>Certified copies of the priority documents have</li> </ol>	been received.		
<ol><li>Certified copies of the priority documents have</li></ol>	been received in Application No	·	
3.   Copies of the certified copies of the priority does	cuments have been received in this	national stage applica	tion from the
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:			
<ul> <li>5. Acknowledgment is made of a claim for domestic priority uper reference was included in the first sentence of the specification.</li> <li>(a) The translation of the foreign language provisional at a Acknowledgment is made of a claim for domestic priority upen the first sentence of the specification or in an Application.</li> </ul>	ation or in an Application Data Sheef pplication has been received. nder 35 U.S.C. §§ 120 and/or 121 s	t. 37 CFR 1.78.	
Applicant has THREE MONTHS FROM THE "MAILING DATE" of below. Failure to timely comply will result in ABANDONMENT of	this communication to file a reply c	omplying with the requ	irements noted EXTENDABLE
7. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give	itted. Note the attached EXAMINERes reason(s) why the oath or declara	R'S AMENDMENT or Nation is deficient.	OTICE OF
<ul> <li>8. ☐ CORRECTED DRAWINGS (as "replacement sheets") must</li> <li>(a) ☐ including changes required by the Notice of Draftspers</li> <li>1) ☐ hereto or 2) ☐ to Paper No</li> <li>(b) ☐ including changes required by the proposed drawing or</li> </ul>	on's Patent Drawing Review ( PTO-	een approved by the E	
(c) ☐ including changes required by the attached Examiner's	s Amendment / Comment or in the 0	Office action of Paper	No
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t	.84(c)) should be written on the drawi he margin according to 37 CFR 1.121(	ngs in the front (not the	a back) of
9. DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT FOR T			Note the
Attachment(s)			
1☐ Notice of References Cited (PTO-892)	5☐ Notice of Informal Pa	atent Application (PTC	)-152)
<ul> <li>2 Notice of Draftperson's Patent Drawing Review (PTO-948)</li> <li>3 Information Disclosure Statements (PTO-1449 or PTO/SB/08), Paper No</li> </ul>	6∐ Interview Summary (	(PTO-413), Paper No.	·
	A Lyammer's Amendi		
4☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	8⊠ Examiner's Statemen	nt of Reasons for Allov	wance
Charles Notes			
✓David Nelms Supervisory Patent Examiner			
Technology Cente: 2600			

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## **EXAMINER'S AMENDMENT**

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows: Cancel claims 1-8 and 11-21.

## **REASONS FOR ALLOWANCE**

The following is an examiner's statement of reasons for allowance: There is no prior art of record that teaches or suggests a film formation method that includes setting different temperatures to a material plural times to form a purified material by sublimation; and forming a thin film on a substrate using the purified material immediately after the setting step.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Renee R Berry whose telephone number is (571) 272-1774. The examiner can normally be reached on M-F 9-5:30.

**RRB** 

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January 26, 2004

David Nelms
Supervisory Patent Examiner
Technology Center 2800